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System Identification: Latest Advances and Prospects

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Message from the Guest Editors

System identification is currently one of the most advanced and continuously developing engineering techniques that allow for mathematical modeling. Its application area is extremely wide — from physical processes investigations, through vehicle dynamics studies, and even analyses of celestial bodies. Even though it has been in use since 1795 (C.F. Gauss), due to the infinite possibilities of this approach numerous aspects are still widely investigated. This special issue is focused on the recent developments in system identification, and its application on a variety of objects and physical processes.











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Message from the Editor-in-Chief

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